



Receipt

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of: Madurawe, et al.

Attorney Docket No.: ALTRP022D2

Application No.: 10/620,917

Examiner: Not yet assigned

Filed: July 15, 2003

Group: 2818

Title: APPARATUS AND METHOD FOR  
MARGIN TESTING SINGLE POLYSILICON  
EEPROM CELLS

**CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as first-class mail on October 3, 2003 in an envelope addressed to the Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450.

Signed: \_\_\_\_\_

Tara Hayden

**REQUEST FOR CORRECTED FILING RECEIPT**

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Sir:

Enclosed is a copy of the Filing Receipt for the above-identified patent application. Please reprint the Filing Receipt as follows and mail the corrected copy to the undersigned.

Change the Inventor "Bruce E. Mielk" to --Bruce E. **Mielke**--.

Since this is a Patent Office typographical error, no fee should be due. However, the Commissioner is authorized to charge any fees that may be due to Deposit Account 500388 (Order No.ALTRP022D2).

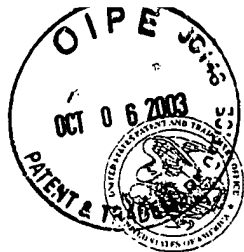
Respectfully submitted,

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## UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/620,917	07/15/2003	2818	750	ALTRP022D2	14	12	1

CONFIRMATION NO. 8946

22434  
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## FILING RECEIPT



\*OC000000010844255\*

Date Mailed: 09/09/2003

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).**

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## Assignment For Published Patent Application

Altera Corporation;

## Domestic Priority data as claimed by applicant

This application is a DIV of 09/874,716 06/04/2001  
 which is a DIV of 08/995,873 12/22/1997 PAT 6,268,623  
 which claims benefit of 60/041,026 03/20/1997

## Foreign Applications

If Required, Foreign Filing License Granted: 09/05/2003

Projected Publication Date: Request for Non-Publication Acknowledged

Non-Publication Request: Yes

Early Publication Request: No

BEYER & THOMAS  
 Docketed  
 Date  
 SEP 11 2003  
 Rfm  
 BEATSEA



Apparatus and method for margin testing single polysilicon EEPROM cells

Preliminary Class

365

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